

December 16, 2003

To: Commissioner of Patents and Trademarks  
Washington, D.C. 20231

Fr: George O. Saile Reg. No. 19,572  
28 Davis Avenue  
Poughkeepsie, N.Y. 12603

Subject:

**Divisional Patent Application of**  
Serial No.: 10/227,697 8/26/02

WENHE LIN, MEI SHENG ZHOU, KIN LEONG PEY,  
SIMON CHOOI

METHODS TO FORM DUAL METAL GATES BY  
INCORPORATING METALS AND THEIR CONDUCTIVE  
OXIDES

#### **PRELIMINARY AMENDMENT**

Dear Sir:

This is a preliminary amendment for the above referenced Divisional Patent Application. Please amend the above identified application for patent as follows:

#### **CERTIFICATE OF MAILING**

I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail in an envelope addressed to: Commissioner of Patents and Trademarks, Washington, D.C. 20231, on December 16, 2003.

Stephen B. Ackerman, Reg. No. 37,761

Signature/Date

 12/16/03